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SCULLY, SCOTT, MURPHY & PRESSER



Examiner Long Pham
Art Unit: 2814

Fax: 571-273-8300

Pages: 13 pages including fax cover sheet

Phone:

Date: 11/21/2005

U.S. Patent Appln. No. 10/662,900
Docket: YOR920030218US1 (16714)
Confirmation No. 1278

Ce:

RESPONSE TO OFFICE ACTION

Please see the following documents:

- 1. Amendment Transmittal (in duplicate)
- 2. Authorization to charge IBM deposit account
- Response under 37 C.F.R. § 1.111
- 4. Certificate of transmission by facsimile dated November 21, 2005

If you have any questions concerning this facsimile please contact Vivian Henriquez at 516-742-4343. Thank you.

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Docket No. **CERTIFICATE OF TRANSMISSION BY FACSIMILE (37 CFR 1.8)** Applicant(s): Cyril Cabral, Jr. et al. YOR920030218US1 (16714) Application No. Filing Date Examiner **Group Art Unit** 10/662,900 23389 September 15, 2003 Long Pham Invention: REDUCTION OF SILICIDE FORMATION TEMPERATURE ON SIGE CONTAINING SUBSTRATES

I hereby certify that this		Response Under 37 C.F.R. § 1.111				
		(Identify type of correspondence)				
is being	facsimile transmitted to the United	States Patent and Trademark Office (Fax. No. 571-273-8300				
on	November 21, 2005					
	(Date)					
		Leslie S Szivos, Ph.D.				
		(Typed or Printed Name of Person Signing Certificate)				
		214				
		(Senature)				

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		N	W 2 1 3	2005						
AMENDMENT TRANSMITTAL LETTER (Large Entity) Applicant(s): Cyril Cabral, Jr. et al.							Docket No. YOR920030218US1 (16714)			
Application No. 10/662,900	Filing Date September 15, 2003	Examiner Long Pham		Customer N 23389	lo.	Group Art Un 2814	Confirmation No.			
Invention: REDUCTION OF SILICIDE FORMATION TEMPERATURE ON SIGE CONTAINING SUBSTRATES										
COMMISSIONER FOR PATENTS: Transmitted herewith is an amendment in the above-identified application.										
The tee has been	calculated and is trans	mitted as shown below								
CLAIMS AS AMENDED										
	CLAIMS REMAINING AFTER AMENDMENT	HIGHEST # PREV. PAID FOR	1	PRESENT		RATE	ADDITIONAL FEE			
TOTAL CLAIMS	17 -	27 =		0	X	\$50.00	\$0.00			
INDEP. CLAIMS	2 -	3 =		0	x	\$200.00	\$0.00			
Multiple Depender	Multiple Dependent Claims (check if applicable)									
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT \$0.00										
No additional fee is required for amendment. Please charge Deposit Account No. in the amount of A check in the amount of to cover the filing fee is enclosed. The Director is hereby authorized to charge payment of the following fees associated with this communication or credit any overpayment to Deposit Account 50-0510/IBM Any additional filing fees required under 37 C.F.R. 1.16. Any patent application processing fees under 37 CFR 1.17. Payment by credit card. Form PTO-2038. WARNING: Information on this form may become public. Credit card information should not be included on this form. Provide credit card information and authorization on PTO-2038. Dated: November 21, 2005 Dated: November 21, 2005 I hereby certify that this correspondence is being deposited with the lighted States Postal Service with sufficient postage as first class final in an envelope addressed to 'Commissioner' for Patents, P.O. Box 1:50, Alexandria, VA 22313-1450' 12 CFR 1.8(a)] on										
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	MENT TRANSMI' ril Cabral, Jr. et al.		Docket No. YOR920030218US1 (16714)							
Application No. 10/662,900			Customer 23389	No.	Group Art Unit 2814	Confirmation No. 1278				
Invention: REDUCTION OF SILICIDE FORMATION TEMPERATURE ON SIGe CONTAINING SUBSTRATES										
COMMISSIONER FOR PATENTS: Transmitted herewith is an amendment in the above-identified application. The fee has been calculated and is transmitted as shown below.										
THE 166 HAS DEEN	Calculated and is trains	:								
		CLAIMS AS AM		Τ						
	CLAIMS REMAINING	HIGHEST #	NUMBER EXTRA		RATE	ADDITIONAL				
TOTAL CLAIMS	AFTER AMENDMENT 17 -	PREV. PAID FOR 27 =	CLAIMS PRESENT 0	x	\$50.00	FEE \$0.00				
INDEP. CLAIMS	2 -	3 =	0	x	\$200.00	\$0.00				
Multiple Dependent Claims (check if applicable)				1	•	\$0.00				
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT \$0.00										
No additional fee is required for amendment. □ Please charge Deposit Account No. in the amount of □ A check in the amount of to cover the filing fee is enclosed. □ The Director is hereby authorized to charge payment of the following fees associated with this communication or credit any overpayment to Deposit Account 50-0510/IBM □ Any additional filing fees required under 37 C.F.R. 1.16. □ Any patent application processing fees under 37 CFR 1.17. □ Payment by credit card. Form PTO-2038. WARNING: Information on this form may become public. Credit card Information should not be included on this form. Provide credit card Information and authorization on PTO-2038. Dated: November 21, 2005										
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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Cyril Cabral, Jr., et al.

Examiner: Long Pham

Serial No:

10/662,900

Art Unit: 2814

Filed:

September 15, 2003

Docket: YOR920030218US1 (16714)

For: REDUCTION OF SILICIDE

FORMATION TEMPERATURE ON SIGE CONTAINING SUBSTRATES

Dated: November 21, 2005

Confirmation No: 1278

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Mail Stop: Amendment Commissioner for Patents P.O. Box 1450

Alexandria, VA 22313-1450

RESPONSE UNDER 37 C.F.R. § 1.111

Sir:

In response to the Office Action dated August 22, 2005, Applicants submit the following amendments and remarks for entry into the record of the above-identified patent application.

CERTIFICATION OF FACSIMILE TRANSMISSION

I hereby certify that this document is being filed in the United States Patent and Trademark Office on the date shown below via facsimile transmission to Mail Stop Amendment, Commissioner for Patents, PO Box 1450, Alexandria, VA 22313-1450 at United States Patent and Trademark Office facsimile transmission number (571) 273-8300.

Dated: November 21, 2005

Leslie S. Szivos